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Rajshahi University of Engineering and Technology



Department of Electrical & Electronic Engineering

Course no.

EEE 4166

Course title:

Processing & Fabrication Technology Sessional

Experiment no.

5

Experiment name:

Characterization of ZnO thin film from XRD analysis and UV/Vis spectrophotometer

Date of experiment:

July 26, 2023

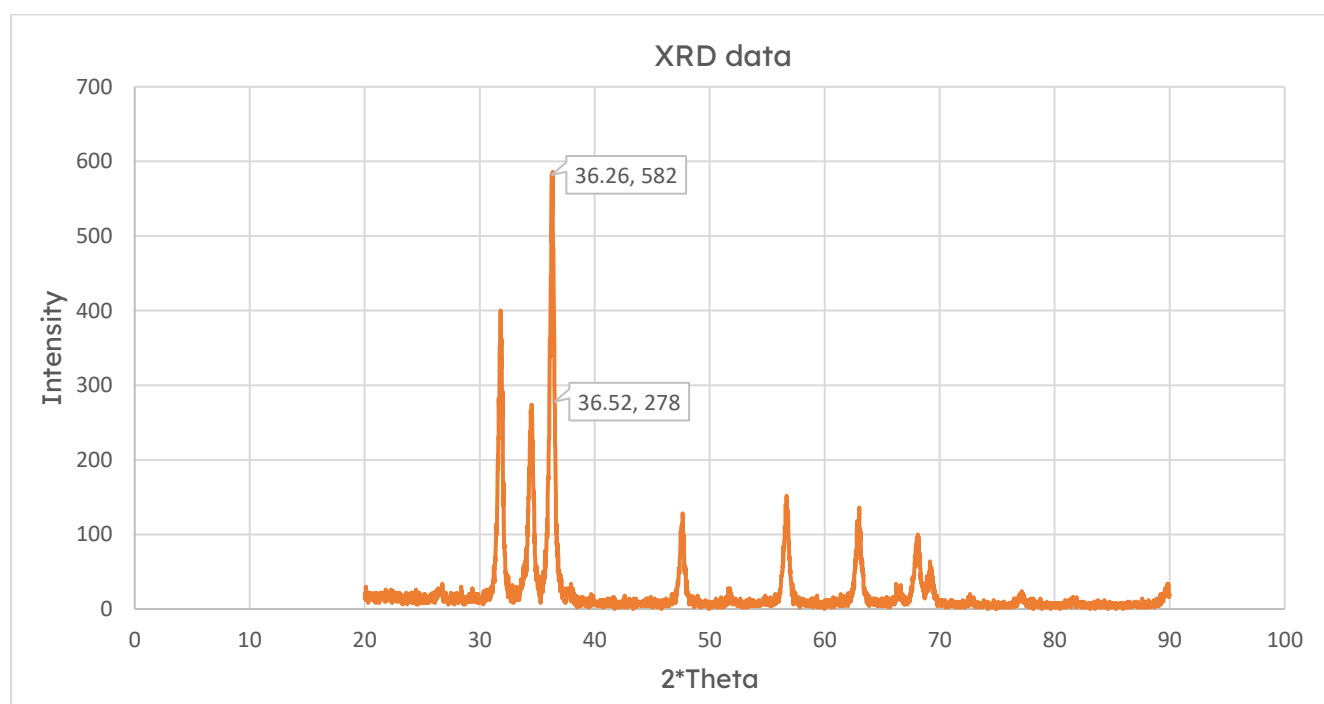
Date of submission:

August 1, 2023

Submitted to:	Submitted by:
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Data table 5.1: XRD data for film thickness calculation

Sl. No.	2*Theta	Intensity	Sl. No.	2*Theta	Intensity
1	20	20	101	21.98	14
2	20.02	18	102	22	14
3	20.04	18	103	22.02	22
4	20.06	20	104	22.04	14
5	20.08	12	105	22.06	14
.....
.....
99	21.94	12	3499	89.98	18
100	21.96	12	3500	90	18

**Fig. 5.1:** Intensity VS 2*theta graph from XRD data for film thickness analysis**Data table 5.2:** UV/Vis data for band gap calculation

wave	%Trans.	Trans.	log term	alpha	h _v	(αh _v) ^{.5}	(αh _v) ²
900	54.51	0.5451	2.263524	5212895	1.377778	2679.964809	13633787.91
899	54.474	0.54474	2.263811	5213556	1.37931	2681.62486	13681068.99
898	52.986	0.52986	2.275839	5241257	1.380846	2690.236112	13799758.72
.....
.....
894	54.391	0.54391	2.264473	5215081	1.387025	2689.506644	13915972.94
893	54.342	0.54342	2.264864	5215983	1.388578	2691.244672	13965189.03

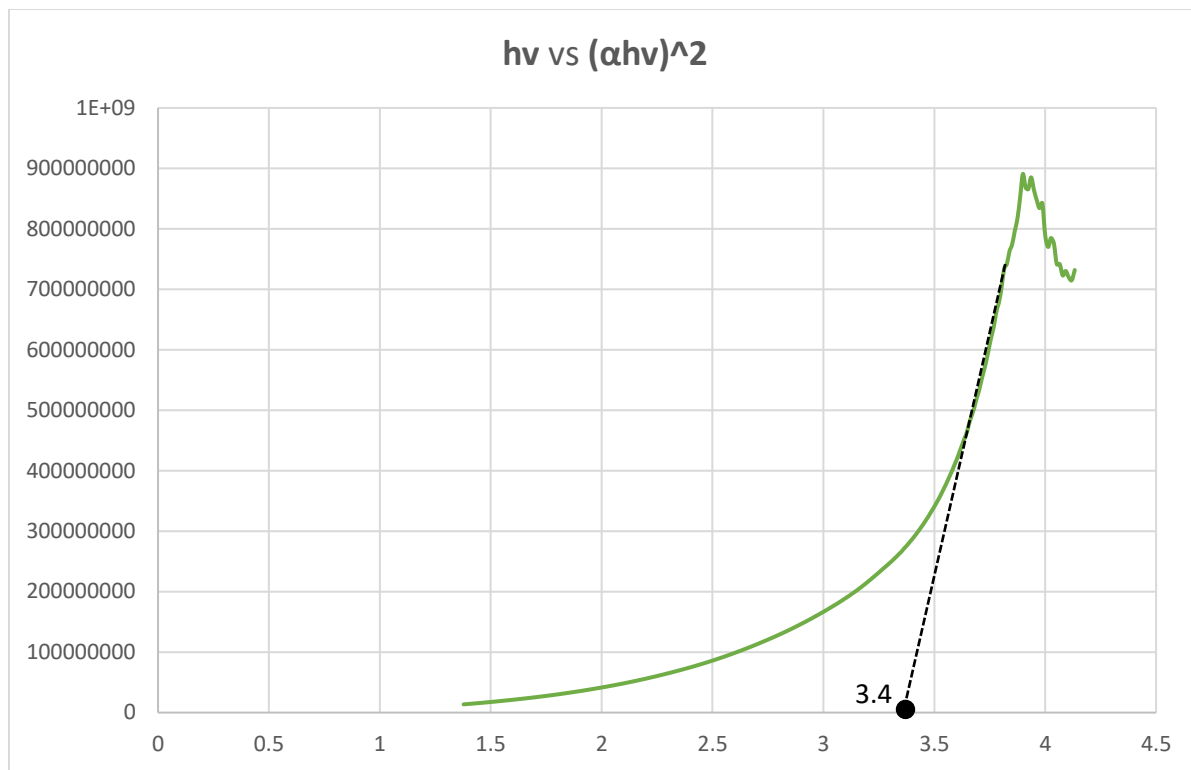


Fig. 5.2: $h\nu$ vs $(\alpha h\nu)^2$ graph from UV/Vis data for direct band gap analysis

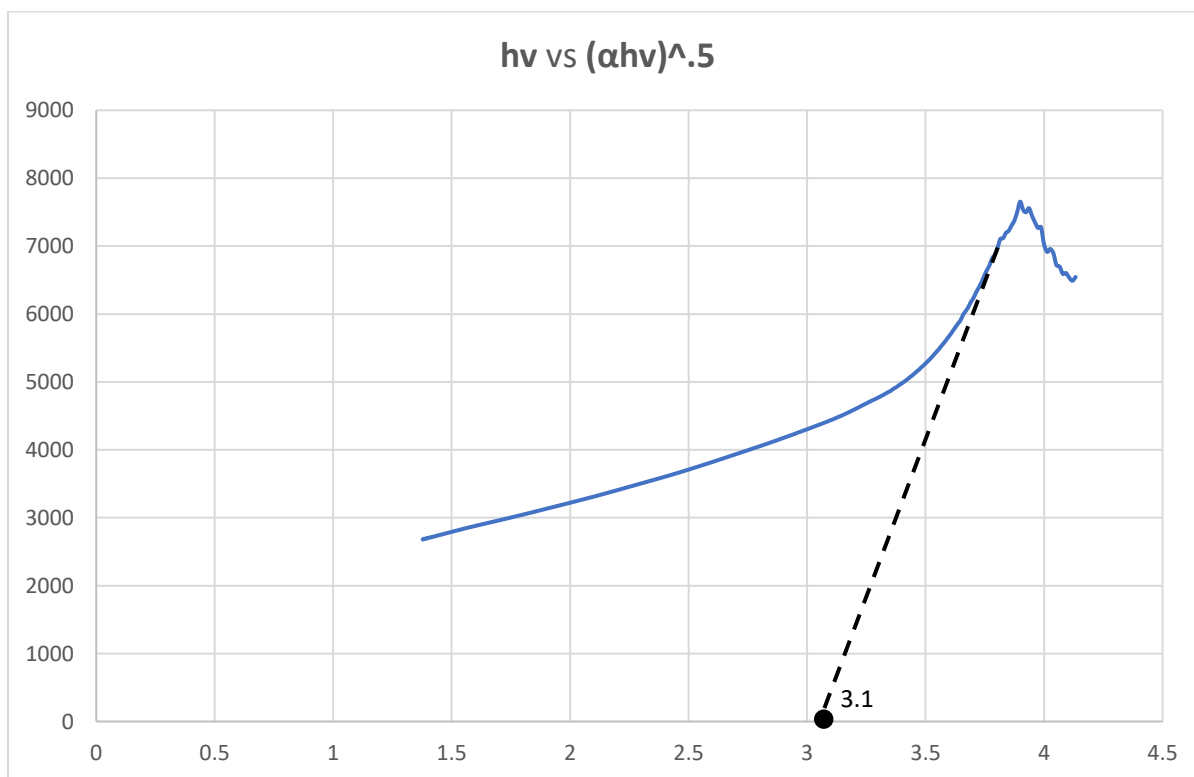


Fig. 5.3: $h\nu$ vs $(\alpha h\nu)^{0.5}$ graph from UV/Vis data for indirect band gap analysis